EXPRESS MAIL NO. EV371410951US

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Serial No:

EXPRESS MAIL NO. EV371410951US

Filing Date:

Filed herewith

Applicant:

Frank M. Cerio, Jr. et al.

Title:

IONIZED PHYSICAL VAPOR DEPOSITION (iPVD) PROCESS

Atty Docket:

TAZ-259

MS Patent Application Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

INFORMATION DISCLOSURE STATEMENT

In accordance with the duty of candor and good faith imposed by 37 CFR §1.56 and means of complying therewith according to 37 CFR §§1.97 and 1.98, the references listed on the attached PTO-1449 are called to the attention of the United States Patent and Trademark Office in connection with the above-identified patent application.

This application was filed after June 30, 2003, and therefore, no copies are enclosed of the U.S. Patents or Published applications cited as references herein.

No admission is made that the cited art represents the prior art or that the cited art is the most material art. Applicant submits that none of the cited references alone or in combination disclose or render obvious the subject matter in the present invention. The Examiner is urged to consider the cited references and to make an independent decision with respect to their materiality.

Respectfully submitted,

WOOD, HERRON & EVANS,

C. Richard Eby, Reg. No. 25,854

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Sheet 1 (A) of 1

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INFORMATION DISCLOSURE STATEMENT BY APPLICANT												APPLICANT Cerio, Jr., et al.				
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